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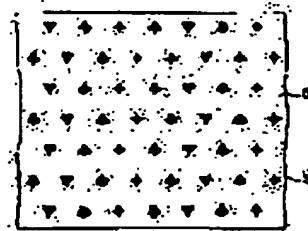
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(54) TRANSFER FOIL OF REFLECTION TYPE RELIEF HOLOGRAM AND SELECTIVE TRANSFER METHOD OF REFLECTION TYPE RELIEF HOLOGRAM USING THIS

(57)Abstract:

**PURPOSE:** To simply and easily form transfer hologram patterns of fine patterns in a large area.

**CONSTITUTION:** Adhesives 9 are selectively applied to the selective pattern regions on the surface of a base body 6 or the surface of the reflection layer of the transfer foil and the reflection layer of the transfer foil is superposed toward the surface of the base body and a base film 4 is peeled after the solidification of the adhesives in order to selectively transfer the reflection type relief holograms on the arbitrarily selected patterns on the surface of the base body 6 by using the transfer foil 10 consisting of a resin layer 1 formed with fine rugged patterns of relief holograms, etc., on the surface, the reflection layer 2 formed on the rugged surface thereof and the base film 4 which is provided on the surface of the resin layer on the side opposite from the reflection layer and is laminated via a release layer 3. The reflection type relief holograms are selectively transferred only in the regions coated with the adhesives in such a manner.



### LEGAL STATUS

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